JS301-150 Spin Coater

150 mm Spin Coater

The JS301-150 benchtop series of small substrate spincoaters is designed for versatility, ease of use and safety in a variety of research and development processes. This spincoater is ideal for processes such as the coating and developing of silicon wafers, glasses, large photomasks, reticles.

- Robust structure
- Easy to use
- Repeatable performance
- Flexibility
- Economical benchtop system

Specification

Programmable 3 steps, 3 speeds
Digital RPM meters and timers
Acuracy +- 1 % at set RPM
Max RPM: 6,000
Acceleration: 3,000RPM/sec.
SUS304 body and bowl
for easy cleaning and chemical resistance
Drain port
Clear PC cover for bowl
Max 150mm diameter & 100x100mm plate
Standard dry vacuum pump: 100 liter/ min, 0.5 ATM

Dimension 350W x 450D x 275H mm 220VAC, 60Hz, 3 amp

Maight: 20 Kg

Standard sample chuck

Weight: 20 Kg





